

Improving the Ionic Conductivity of the LLZO–LZO Thin Film through Indium Doping

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Table S1. The thickness of In₂O₃ thin film after repeating depositing 120 layers.

Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	The average thickness (nm)
A1	701.4	A2	708.4	A3	715.6	A4	731.5	720.4
B1	712.3	B2	741.3	B3	718.7	B4	729.4	
C1	705.8	C2	732.6	C3	726.6	C4	727.3	
D1	704.5	D2	727.3	D3	725.2	D4	718.6	

Table S2. The thickness of LLZO thin film after repeating depositing 80 layers.

Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	The average thickness (nm)
A1	544.6	A2	563.3	A3	554.9	A4	569.6	560.2
B1	554.7	B2	575.7	B3	565.1	B4	552.4	
C1	562.8	C2	571.2	C3	566.6	C4	548.4	
D1	548.6	D2	554.7	D3	568.6	D4	561.9	

Table S3. The thickness of Li₂CO₃ thin film after repeating depositing 400 layers.

Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	Samples	Thickness (nm)	The average thickness (nm)
A1	317.2	A2	319.1	A3	324.0	A4	324.4	319.9
B1	322.1	B2	325.2	B3	317.4	B4	326.6	
C1	314.7	C2	315.1	C3	325.3	C4	313.6	
D1	317.7	D2	323.0	D3	316.3	D4	323.5	